Enhancing the performance and stability of organic solar cells using solution processed MoO₃ as hole transport layer

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Bulk-heterojunction (BHJ) organic solar cells (OSCs) have attracted great attention in recent years because of their low cost, easy fabrication, simple device structure, promising applications, light-weight properties, potential for large-area devices and their possibility to flex, roll, fold for portability.

In the past few years, in order to achieve commercial application, many efforts have been made to improve the power conversion efficiency (PCE) of BHJ OSCs. Considerable progress has been made in the improvement of these devices, and the achieved efficiencies have evolved from less than 1% in a poly(phenylene vinylene) (PPV) system in 1995, to approaching 5% in the most representative (3-hexylthiophene) (P3HT):(6,6)-phenyl-C₆₁-butryic acid methyl ester (PCBM) system in 2005, to 12.7% in a novel polymer material system in 2017. To date, the most traditionally and frequently employed hole transport layer in BHJ OSCs is poly(3,4-ethylenedioxythiophene):poly(styrenesulfonate) (PEDOT:PSS). The reason is that PEDOT:PSS has a good hole transporting ability, high transparency, smooth morphology and high work function, that PEDOT:PSS has a good hole transporting ability, high transparency, smooth morphology and high work function.

Fourthly, PEDOT:PSS is not an effective electron-blocking layer because of the leakage current to the anode. To solve these problems, inorganic p-type-like metal oxide materials such as NiO, V₂O₅, MoO₃, WO₃, CrO₃ with high work function and good hole conductivity were developed to try to replace PEDOT:PSS as the hole transport layers. However, relatively expensive vacuum preparation are incompatible with the concept of low-cost, solution-processable and roll-to-roll OSCs. Therefore, there is an urgent demand for the hole transport layer to develop some cost-efficient and simply processed preparation method.

For this purpose, solution processed MoO₃ (s-MoO₃) has drawn great attention as an hole transport layer for OSCs with high-performance, owing to its relatively good hole mobility, environmental stability, and transparency in the range of visible light. Recently, several kinds of preparation methods of s-MoO₃ were reported in OSCs. MoO₃ solutions were mainly prepared by hydrate and sol–gel methods. However, on one hand, some methods need high temperature treatment; on the other hand, even if it can be able to obtain the MoO₃ solutions, the preparation process is still relatively complex and some organic solvents is not friendly to the environment.

In this work, we provide a simple and cost-effective procedure to prepare a continuous and uniform s-MoO₃ layer to act as the hole transport layer for OSCs. We used three kinds of annealing treatment on s-MoO₃ film for comparison: no annealing, 100 °C thermal annealing, and UV annealing. Among them, the performance of the s-MoO₃ film under UV annealing mode is better. So, the performance of P3HT:ICBA based OSCs could be obtained the optimized PCE of 5.4% and a better air stability. The influence of annealing mode for s-MoO₃ thin films in OSCs will be discussed in the views of transmittance, surface morphology, valence state and air stability.

1. Introduction

Bulk-heterojunction (BHJ) organic solar cells (OSCs) have attracted great attention in recent years because of their low cost, easy fabrication, simple device structure, promising applications, light-weight properties, potential for large-area devices and their possibility to flex, roll, fold for portability. In the past few years, in order to achieve commercial application, many efforts have been made to improve the power conversion efficiency (PCE) of BHJ OSCs. Considerable progress has been made in the improvement of these devices, and the achieved efficiencies have evolved from less than 1% in a poly(phenylene vinylene) (PPV) system in 1995, to approaching 5% in the most representative (3-hexylthiophene) (P3HT):(6,6)-phenyl-C₆₁-butryic acid methyl ester (PCBM) system in 2005, to 12.7% in a novel polymer material system in 2017. To date, the most traditionally and frequently employed hole transport layer in BHJ OSCs is poly(3,4-ethylenedioxythiophene):poly(styrenesulfonate) (PEDOT:PSS). The reason is that PEDOT:PSS has a good hole transporting ability, high transparency, smooth morphology and high work function, which is suitable for the highest occupied molecular orbital (HOMO) of most donor-type semiconductors. However, the instability of OSCs with PEDOT:PSS as the hole transport layer is not satisfying for their future applications. Firstly, water is easily adsorbed by the PEDOT:PSS layer due to its hygroscopic property. Secondly, the work function of the PEDOT:PSS layer is very sensitive to water. Thirdly, PEDOT:PSS maybe yield inhomogeneous film morphologies and unstable electrical properties.

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2. Experimental details

Fluorinated tin oxide (FTO) coated glass ($R = 12–14 \, \Omega \, \text{sq}^{-1}$) was cut into 3 cm w2.5 cm chips as substrates. The chips were ultrasonicated in 30 °C aqueous detergent followed by deionized (DI) water, acetone and then alcohol for 10 min each. The substrates were dried under a stream of nitrogen. Subsequently, the FTO-coated glass substrates were treated for 15 min by UV-O$_3$ in order to ameliorate the hydrophilic property. MoO$_3$ solutions were prepared by a thermal decomposition method using ammonium heptamolybdate (NH$_4$)$_6$Mo$_7$O$_{24}$·4H$_2$O as a precursor. 0.4 g (NH$_4$)$_6$Mo$_7$O$_{24}$·4H$_2$O was dissolved in 10 mL DI water. In order to form MoO$_3$ nanoparticles favorably, a small amount of hydrochloric acid was added into the solution providing acidic environment. The mixed solution was heated at 80 °C for 1 hour in air. (NH$_4$)$_6$Mo$_7$O$_{24}$·4H$_2$O was decomposed to three components, MoO$_3$, NH$_3$ and H$_2$O. NH$_3$ evaporated into the air and MoO$_3$ is the only solute in the solution. The resulting solution was diluted by DI water to 0.1 wt% concentrations. Then 10 mL solution was took for standby.

In order to obtain an ultrasmooth MoO$_3$ thin film, we have added a small amount of PEDOT:PSS (about 0.1 mL) into the solution. PEDOT:PSS has been diluted very seriously. As we all know, PEDOT:PSS is purchased and refrigerated, then spin-coated directly. After serious dilution, it’s unlikely a mixed film and it’s impossible to act as hole transport layer in the OSCs. In our work, we mainly used the small amount of PEDOT:PSS to increase the surface flatness of s-MoO$_3$ ultra-thin film after spin-coating. Then, the MoO$_3$ solutions were spin-coated onto FTO substrates at 3000 rpm. No annealing treatment, 100 °C thermal annealing treatment and UV annealing treatment for the s-MoO$_3$ films before organic active layer deposition was carried out. In order to reduce the unnecessary loss and some trouble of preparation for the possibility of large scale production in the future, we made a try to prepare the MoO$_3$ thin film by a simpler solution process similar to the method to prepare the commonly used PEDOT:PSS thin film. So, we make PEDOT:PSS as reference. As a comparison, PEDOT:PSS was spin-coated on FTO substrates at 750 rpm for 10 s, then 2000 rpm for 20 s. The resulting PEDOT:PSS film was heated on a hot plate at 80 °C for 15 min and the thickness was about 30–35 nm. Subsequently, the active layer was spin-coated from a solution containing P3HT:ICBA (1 : 1, w/w) in chlorobenzene on the top of hole transport layers at 450 rpm for 10 s, then 1000 rpm 20 s (thickness = 210 nm). And then the samples were immediately put into the evaporator to deposit LiF (thickness = 1.5 nm) and Al top electrodes (thickness = 100 nm) under a pressure of about 4 0010$^{-4}$ Pa. The active area of device is 4 mm$^2$. Finally, the fabricated devices were post annealed at 150 °C under Ar ambient for 10 min in argon-filled glove box.

The deposition rate as well as the nominal film thickness was monitored with a quartz crystal thickness monitor (TM-400, Maxtek, USA). Using a surface profilometer (FTS2-54C-3D, Taylor Hobson, UK), the film thicknesses were checked and good agreement was obtained. The morphology of the hole transport layer thin film was characterized by atomic force microscopy (AFM, SPM-9500j3) in tapping mode. The transmittance spectra of films were measured by a UV-visible (vis)-near IR (NIR) spectrophotometer (CARY 5000, Varian, Australia) in the 200–800 nm wavelength range at room temperature. Film crystal structure was characterized by X-ray diffraction (XRD, Bruker AXS, D8 Advance) using CuK$\alpha$ radiation at 40 kV and 40 mA. The compositions and chemical states of the molybdenum oxide films were examined by X-ray photoelectron spectroscopy (XPS, XSAM800). The performances of the devices were determined using a calibrated AM1.5G solar simulator under illumination operating at light intensity of 100 mW cm$^{-2}$. The current–voltage curves were obtained using a standard source measurement unit (Keithley 2400). From this, the fill factor (FF) and the PCE of the device were calculated. The used polymers’ chemical structures, the schematic diagram of proposed OSC, and the energy level diagram of materials are shown in Fig. 1.

3. Results and discussion

The PCE of the OSCs based on P3HT:PCBM reached over 4% (ref. 7–9) by thermal treatment, solvent* and vapor* annealing, as well as mixture solvent treatment. However, further improvement of the photovoltaic performance of the OSCs based on P3HT:PCBM is limited because of the relatively small energy difference between the lowest unoccupied molecular orbital (LUMO) of PCBM and the HOMO of P3HT, which results in a lower open circuit voltage ($V_{oc}$) of the P3HT:PCBM based OSCs to ~0.6 V. In order to further improve device performance, a novel ICBA$^{-11}$–14 with a higher LUMO energy level of ~3.74 eV which is higher than that of PCBM was employed as photovoltaic electron acceptor with matching up P3HT as photovoltaic electron donor. In theory, it will results in a higher $V_{oc}$ and PCE in the P3HT:ICBA based OSCs.

LiF ultrathin film acted as electron collecting buffer layer in OSCs. The pre-evaporated LiF buffer layer before the deposition of Al electrode can effectively prevent the Al atoms of high energy from directly bombarding the polymer active layer. LiF was inserted as the cathode buffer layer that can isolate the cathode from the polymer active layers with avoiding forming “C–Al” bond, improving the quality of the interface and reducing the recombination probability of the excitons. LiF can decline the work function of the cathode at the interface and provide a good ohmic contact between the polymer active layer and the cathode. The series resistance will be decreased, and then the FF of the OSCs will be improved. After inserting a LiF thin film layer, a build-in electric field pointing from Al to polymer will be formed inside the polymer/LiF/Al system. The build-in field can push the electrons passing through the buffer layer. So the short-current density ($J_{sc}$) of the cells could also be increased.

At the same time, a buffer layer used for modifying anode plays an important role in the device performance. With the insertion of s-MoO$_3$ thin film layer, the energy levels make it act as an efficient exciton blocking layer to mainly prevent electrons to reaching the anode due to the large energy band gap of s-MoO$_3$. The energy of s-MoO$_3$ and the HOMO energy of P3HT matched well (shown in Fig. 1). Holes can be extracted to anode...
easily. Therefore, s-MoO₃ thin film would play a significant impact on the performance of OSCs.

We mainly discussed the s-MoO₃ thin film in the views of annealing mode which affects the performance and the stability of OSCs. In this work, the ultrathin s-MoO₃ film was treated by three annealing modes: no annealing, 100 °C thermal annealing and UV annealing.

3.1 Optical characteristics of s-MoO₃ films

The UV-visible light absorption spectra of P3HT:ICBA and transmission spectra of PEDOT:PSS and s-MoO₃ with different annealing modes on FTO are shown in Fig. 2. In accordance with the condition of device fabrication, we use the thin films with the same states to investigate their absorption and transmission. The transmission characteristics of the anode buffers layer were similar to each other. However, a slight decrease in transmission in s-MoO₃ films was observed in the wavelength range of 480–800 nm from UV annealing, thermal annealing to no annealing, which could result in less light loss in the device because of the increase of optical transmission across the entire visible spectrum by ≤10%. As shown in Fig. 2 we can see that the transmittance of s-MoO₃ by UV annealing treatment is higher than that of PEDOT:PSS from 450 nm to 650 nm in the main area of the spectra. The amelioration of transmission for hole transport layer could be beneficial to the performance of OSCs. We attribute the increase of optical transmission to the removal of contaminations and the change of refraction in the metal oxide because of different valence state and different surface roughness by UV annealing treatment on s-MoO₃ film.

3.2 Surface analysis of s-MoO₃ films

Fig. 3 shows the tapping mode AFM micrographs of the FTO/s-MoO₃ samples with different annealing modes including only FTO for comparison. It can be seen that the samples of FTO, FTO/s-MoO₃ (no annealing), FTO/s-MoO₃ (100 °C thermal annealing), and FTO/s-MoO₃ (UV annealing) have a surface roughness of 18.68 nm, 17.75 nm, 16.70 nm, and 15.81 nm root-mean-square (rms), respectively.

As we all know, besides needing an appropriate device structure, thin film layers in devices are expected as smooth as possible. For ultrathin s-MoO₃ layers under different annealing modes, each film was found to exhibit similar surface structures as shown in Fig. 3.
3.3 X-ray photoelectron spectroscopy of s-MoO$_3$ films

We used XPS to understand the valence state of Mo in s-MoO$_3$ films. Fig. 4 shows the Mo 3d XPS spectra of s-MoO$_3$ films with different annealing modes. As shown in Fig. 4(a) the Mo 3d XPS spectra of s-MoO$_3$ film without annealing treatment contain the peaks of two valence: Mo$^{6+}$ and Mo$^{5+}$ divided by the total peak. The Mo$^{6+}$ fraction calculated as the area under the Mo$^{6+}$ peaks was 92%. The Mo$^{5+}$ fraction was 8%. Fig. 4(b) shows the Mo 3d XPS spectra of s-MoO$_3$ film with 100 °C annealing treatment also contain the peaks of two valence: Mo$^{6+}$ and Mo$^{5+}$. The Mo$^{6+}$ fraction was 96% and the Mo$^{5+}$ fraction was 4%. We can see that after 100 °C annealing treatment the Mo$^{5+}$ fraction was enhanced. That is to say, the quality of the s-MoO$_3$ film was enhanced. We can foresee that the performance of devices would be improved. From the Fig. 4(c), we can see that the Mo 3d XPS spectra of s-MoO$_3$ film with UV annealing treatment basically only contain the peak of one valence: Mo$^{6+}$. In other words, relatively pure s-MoO$_3$ film was obtained. So, better performance of devices would be expected.

3.4 Performance of organic solar cells

To study the effect of different annealing modes on s-MoO$_3$ films, we have fabricated series of devices. Firstly, the structure of FTO/PEDOT:PSS/P3HT:ICBA/LiF/Al was fabricated as a comparison, then the structure of FTO/s-MoO$_3$/P3HT:ICBA/LiF/Al was fabricated with three annealing modes: no annealing, 100 °C thermal annealing and UV annealing to treat the s-MoO$_3$ thin films. The illuminate current density–voltage ($J$–$V$) characteristics under AM1.5G illumination (100 mW cm$^{-2}$) of the OSCs are shown in Fig. 5 and the main extracted performance parameters including $V_{oc}$,$J_{sc}$,$FF$, PCE are summarized in Table 1. The device with PEDOT:PSS as an hole transport layer showed $PCE=5.22$% corresponding to $V_{oc}=0.84\, \text{V}$,$J_{sc}=11.31\, \text{mA cm}^{-2}$, and $FF=55\%$. Then, the no annealed s-MoO$_3$ based devices showed $PCE=4.46\%$ with a small decrease in $V_{oc}$ from 0.84 to 0.82 V, a small decrease in FF from 55% to 54% and a larger decline in $J_{sc}$ from 11.31 to 10.04 mA cm$^{-2}$ in comparison with that of PEDOT:PSS based devices. When we used 100 °C thermal annealing to treat the s-MoO$_3$ thin film, the performance of devices was improved slightly than that of no annealed s-MoO$_3$ based devices, with the increase in $J_{sc}$ from 10.04 to 10.67 mA cm$^{-2}$ and no change in $V_{oc}$, FF. At last, we adopted the UV annealing to treat the s-MoO$_3$ thin film, there was a larger increase on the performance of the devices in comparison with thermal annealed s-MoO$_3$ based devices. After UV annealing for the s-MoO$_3$ thin film, there was no change in $V_{oc}$ with 0.82 V as before, but there was a large enhancement in $J_{sc}$ and FF from 10.67 to 11.50 mA cm$^{-2}$ and 54–58% in comparison with that under thermal annealing mode. Relative to the performance of the devices with PEDOT:PSS as the buffer layer, there was a little decrease in $V_{oc}$ from 0.84 to 0.82 V, but there was a little increase in $J_{sc}$, FF from 11.31 to 11.50 mA cm$^{-2}$, 55–58% respectively. And in the end the PCE was enhanced from 5.22% to 5.4%. It demonstrates that the UV annealed s-MoO$_3$ based devices can get a comparable or even a little better performance than that of PEDOT:PSS based devices.

For $V_{oc}$ numerous studies have demonstrated that $V_{oc}$ depends on the energy gap between the HOMO level of the donor and the LUMO level of the acceptor of the BHJ, forming the basis for predicting the open circuit voltage in the devices. We used the same active layer so that the value of $V_{oc}$ is very similar. The reason for the little decrease in $V_{oc}$ may be that the work function of MoO$_3$ is 5.3 eV with matching that of P3HT very well. However, the work function of MoO$_3$ is 5.3 eV. Generally speaking, it is still thought to match that of P3HT well. But the match of MoO$_3$ is not good as that of PEDOT:PSS. So, the devices with s-MoO$_3$ as the hole transport layer showed a little decrease in $V_{oc}$.

For $J_{sc}$, generally speaking, $J_{sc}$ is mainly determined by the absorption of sunlight by the active layer, the generation of excitons, diffusion, separation, and charge transfer and collection. As shown in Fig. 2 we can see that the transmittance of s-MoO$_3$ by UV annealing treatment is higher than that of PEDOT:PSS from 450 nm to 650 nm in the main area of the spectra. So, it can be foreseen that more light can be absorbed by the active layer. So, the devices with s-MoO$_3$ as the hole transport layer showed a little increase in $J_{sc}$.

For FF, as we all known, FF is related to series resistance and shunt resistance. The series resistance, $R_s$, can be calculated from the inverse slope of the $J$–$V$ curve in the first quadrant.
On the other hand, the shunt resistance $R_{sh}$ is determined by the inverse slope of the $J-V$ curve in the fourth quadrant, as shown in Fig. 5. In general, the $R_s$ is smaller and the $R_{sh}$ is larger, the FF would be larger. From Fig. 5 we can see that the $R_s$ of the device using s-MoO$_3$ by UV annealing treatment as the hole transport layer is smaller than that of the device using PEDOT:PSS as the hole transport layer and the $R_{sh}$ of the device based on s-MoO$_3$ by UV annealing treatment is larger than that of the device based on PEDOT:PSS. So, the devices with s-MoO$_3$ as the hole transport layer showed a little increase in FF.

#### 3.5 Stability of organic solar cells

Besides the PCE, stability of devices is another important aspect which needs to be enhanced. The performance declines dramatically for unencapsulated devices. As we all know the hygroscopic nature of PEDOT:PSS as the hole transport layer in OSCs may lead to unstable devices. To compare the stability of PEDOT:PSS and s-MoO$_3$ based devices, we measured the $J-V$ characteristics of these un-encapsulated devices over 30 days. As shown in Fig. 6(a)–(d), the performance of devices directly stored in the air could significantly decrease with the increase of storage time. From Fig. 6(e), we can see that the PCE of the standard PEDOT:PSS based devices show a nearly exponential decrease according to the fitting curve. The air stability of the devices with s-MoO$_3$ under three different annealing modes as the buffer layers show drastically enhanced than that of PEDOT:PSS based devices. Comparing with no annealing and 100 °C thermal annealing, the UV annealing for s-MoO$_3$ thin film could improve the air stability of devices. The drastic decrease in performance of devices can be considered to arise from invasion of water and oxygen. The poor stability of PEDOT:PSS based devices can be ascribed to the hygroscopic and acidic nature. So, its performance declines dramatically to near 0 and stays a stable value of 0 with the growth of storage.
time. MoO₃ is regarded as a very stable material which can play as a protective thin film layer with preventing undesired physical and chemical influence. As the storage time continues to grow, the performance of the devices with the s-MoO₃ as the hole transport layer will be a stable value of near 0. According to the analysis of XPS above mentioned, the s-MoO₃ thin film treated by UV annealing can display the characteristics of MoO₃. Eventually, the air stability of the devices can be improved.

4. Conclusion

In conclusion, efficient and stable P3HT:ICBA based BHJ OSCs with s-MoO₃ as the hole transport layer was fabricated. We used a facile and cost-effective preparation method to obtain a MoO₃ aqueous solution by thermal decomposition of (NH₄)₆Mo₇O₂₄·4H₂O. The s-MoO₃ ultra-thin film was treated by three annealing modes: no annealing, 100 °C thermal annealing and UV annealing. By UV annealing treatment, the transmittance, surface morphology and film quality of s-MoO₃ film can be enhanced which is favorable to the performance of devices. So, the OSCs using s-MoO₃ by UV annealing treatment as the hole transport layer can obtain a better PCE and a better stability.

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